

ABSTRACT

POLISHING DEVICE AND POLISHING METHOD

5 A polishing device (1) includes a processing vessel (10) into
which workpieces are charged, a fluidizing unit that fluidizes the
workpieces in the processing vessel, an abrasive-feeding unit (30) that
feeds an abrasive into the workpieces, and a suction unit (40) that
10 generates an air flow in a direction in which the abrasive passes through
the processing vessel (10), and recovers the abrasive by suction. The
abrasive fed from the abrasive-feeding unit (30) is allowed to pass
between the workpieces charged into the processing vessel (10) by the
air flow generated from the suction unit (40) while coming into contact
with the workpieces. Accordingly, the workpieces are polished.

15 FIG. 1